

P Murugapandiyan

List of Publications by Year in descending order

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#	ARTICLE	IF	CITATIONS
1	60 GHz Double Deck T-Gate AlN/GaN/AlGaIn HEMT for V-Band Satellites. Silicon, 2022, 14, 5941-5949.	1.8	3
2	A 28-GHz Low-Loss AlGaIn/GaN HEMT for TX/RX Switches in 5G Base Stations. Journal of Electronic Materials, 2022, 51, 1215-1225.	1.0	3
3	UWBG AlN/In _{0.02} Ga _{0.98} O ₃ HEMT on Silicon Carbide Substrate for Low Loss Portable Power Converters and RF Applications. Silicon, 2022, 14, 11079-11087.	1.8	5
4	Influence of High-k Passivation Layer on Gate Field Plate AlGaIn/GaN/AlGaIn Double Heterojunction HEMT. Silicon, 2022, 14, 10437-10445.	1.8	5
5	Nanosheet field effect transistors-A next generation device to keep Moore's law alive: An intensive study. Microelectronics Journal, 2021, 114, 105141.	1.1	50
6	Influence of AlN passivation on thermal performance of AlGaIn/GaN high-electron mobility transistors on sapphire substrate: A simulation study. Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 2021, 273, 115449.	1.7	7
7	High-Performance $\text{In}_{0.13}\text{Al}_{0.83}\text{Ga}_{0.04}\text{N} / \text{AlN} / \text{GaN} / \text{In}_{0.04}\text{Ga}_{0.96}\text{N}$ HEMT for High Power Millimeter Wave Electronics. , 2021, , .		0
8	Investigation of Quaternary Barrier InAlGaIn/GaN/AlGaIn Double-Heterojunction High-Electron-Mobility Transistors (HEMTs) for High-Speed and High-Power Applications. Journal of Electronic Materials, 2020, 49, 524-529.	1.0	9
9	Investigation of ultra-scaled AlN/GaN/InGaIn double heterojunction HEMT for high-frequency applications. International Journal of Electronics Letters, 2020, 8, 472-482.	0.7	3
10	Breakdown voltage enhancement of gate field plate Al _{0.295} Ga _{0.705} N/GaN HEMTs. International Journal of Electronics, 2020, , 1-15.	0.9	9
11	Performance analysis of HfO ₂ /InAlN/AlN/GaN HEMT with AlN buffer layer for high power microwave applications. Journal of Science: Advanced Materials and Devices, 2020, 5, 192-198.	1.5	15
12	Switching Transient Analysis and Characterization of an E-Mode B-Doped GaN-Capped AlGaIn DH-HEMT with a Freewheeling Schottky Barrier Diode (SBD). Journal of Electronic Materials, 2020, 49, 4091-4099.	1.0	16
13	Design and development of cross dipole antenna for satellite applications. Frequenz, 2020, 74, 229-237.	0.6	6
14	GaN-Based High-Electron Mobility Transistors for High-Power and High-Frequency Application: A Review. Lecture Notes in Networks and Systems, 2020, , 339-348.	0.5	4
15	DC and Microwave Characteristics of $20\text{ nm T-Gate Enhancement Mode Al}_{0.5}\text{Ga}_{0.5}\text{N/AlN/GaN/Al}_{0.08}\text{Ga}_{0.92}\text{N}$ High Electron Mobility Transistor for Next Generation High Power Millimeter Wave Applications. Journal of Nanoelectronics and Optoelectronics, 2018, 13, 183-189.	0.1	0
16	DC and microwave characteristics of Lg 50 nm T-gate InAlN/AlN/GaN HEMT for future high power RF applications. AEU - International Journal of Electronics and Communications, 2017, 77, 163-168.	1.7	26
17	DC and microwave characteristics of 20Ånm T-gate InAlN/GaN high electron mobility transistor for high power RF applications. Superlattices and Microstructures, 2017, 109, 725-734.	1.4	11
18	30 nm T-gate enhancement-mode InAlN/AlN/GaN HEMT on SiC substrates for future high power RF applications. Journal of Semiconductors, 2017, 38, 084001.	2.0	6

#	ARTICLE	IF	CITATIONS
19	Static and dynamic characteristics of L g 50Ånm InAlN/AlN/GaN HEMT with AlGaN back-barrier for high power millimeter wave applications. Journal of Science: Advanced Materials and Devices, 2017, 2, 515-522.	1.5	8
20	Design and analysis of 30Ånm T-gate InAlN/GaN HEMT with AlGaN back-barrier for high power microwave applications. Superlattices and Microstructures, 2017, 111, 1050-1057.	1.4	31
21	Investigation of Influence of SiN and SiO ₂ Passivation in Gate Field Plate Double Heterojunction Al _{0.3} Ga _{0.7} N/GaN/Al _{0.04} Ga _{0.96} N High Electron Mobility Transistors. Silicon, 0, , 1.	1.8	8